

FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. ASMEX.328A	APPLICATION NO. 10/074,633
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		
APR 09 2004 <small>(USE SEVERAL SHEETS IF NECESSARY)</small>		
APPLICANT Michael A. Todd		
FILING DATE February 11, 2002		
GROUP 2814		

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)	

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EXAMINER	LONG Pham	DATE CONSIDERED	7/7/04.
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***EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.**

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(USE SEVERAL SHEETS IF NECESSARY)		APPLICANT Michael A. Todd	
		FILING DATE February 11, 2002	GROUP 2814

U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
EP	1.	5,192,714	03/09/93	Suguro et al.			
	2.	5,194,398	03/16/93	Miyachi et al.			
	3.	5,461,250	10/24/95	Burghartz et al.			
	4.	5,563,093	10/08/96	Koda et al.			
	5.	5,869,389	02/09/99	Ping et al.			
	6.	6,013,922	01/11/00	Ueda et al.			
✓	7.	6,365,479	04/02/02	U'Ren			

FOREIGN PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
							YES NO

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)	

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EXAMINER	Long Pham	DATE CONSIDERED	7/7/04
*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 809; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.			

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U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
Lp	1.	5,389,398	02/14/95	Suzuki et al.	427	130	
	2.	5,698,771	12/16/97	Shields et al.	73	31.05	
	3.	6,228,181	05/08/01	Yamamoto et al.	148	33.5	
	4.	6,326,311	12/04/01	Ueda et al.	438	694	
	5.	6,455,892	09/24/02	Okuno et al.	257	328	
	6.	6,613,695	09/02/03	Pomarede et al.	438	767	

FOREIGN PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
							YES

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)
Lp	7. Ikoma et al., Growth of Si/3C-SiC/Si(100) heterostructures by pulsed supersonic free jets, Applied Physics Letters, Volume 75, No. 25, Pp. 3977-3979, December 1999

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U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)	
1. <i>Lp</i>	5,214,002	05/25/93	Hayashi et al.				
2. <i></i>	5,356,821	10/18/94	Naruse et al.				
3. <i></i>	5,471,330	11/28/95	Sarma				
4. <i>V</i>	6,103,600	08/15/00	Ueda et al.				

FOREIGN PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
5. <i>Lp</i>	11317530	16-11-99	Japan (abstract)			X	
6. <i></i>	EP 0368651 A2	16-05-90					
7. <i></i>	EP 0486047 A2	20-05-92					
8. <i></i>	EP 0747974 A2	11-12-96					
9. <i></i>	EP 1065728 A2	03-01-01					
10. <i>V</i>	GB 2332564 A	23-06-99	United Kingdom				

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)	
11. <i>Lp</i>	Olivares, J. et al.; "Solid-phase crystallization of amorphous SiGe films deposited by LPCVD on SiO ₂ and glass," Thin Solid Films 337 (1999) pp. 51-54.	
<i></i>		

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EXAMINER	<i>Long Pham</i>	DATE CONSIDERED	<i>7/7/04</i>
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<p>FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE</p> <p>O I P E J O C E MAY 09 2003 P A T E N T D E M A R X</p> <p>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</p> <p>(USE SEVERAL SHEETS IF NECESSARY)</p>	<p>ATTY. DOCKET NO. ASMEX.328A</p>	<p>APPLICATION NO. 10/074,833</p>
<p>APPLICANT Michael A. Todd</p>		
<p>FILING DATE February 11, 2002</p>		<p>GROUP 2812</p>

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

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OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

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EXAMINER Long Pham DATE CONSIDERED 7/21/04
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APPLICANT Michael A. Todd		FILING DATE February 11, 2002	
		GROUP 2812	

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FOREIGN PATENT DOCUMENTS							
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
Lf	60043485 A	3/8/85	Japan			Abstract	
	61153277 A	7/11/86	Japan			Abstract	
	62078612 A	4/8/87	Japan			Abstract	
	63003414 A	1/8/88	Japan			Abstract	
	63003463 A	1/8/88	Japan			Abstract	
	01217956 A	8/31/89	Japan			Abstract	
	01268064 A	10/25/89	Japan			Abstract	
	02155225 A	6/14/90	Japan			Abstract	
	03091239 A	4/18/91	Japan			Abstract	
	03185817 A	8/13/91	Japan			Abstract	
	03187215 A	8/15/91	Japan			Abstract	
	03292741 A	12/24/91	Japan			Abstract	
	04323834 A	11/13/92	Japan			Abstract	
	05021378 A	1/29/93	Japan			Abstract	
	05062911 A	3/12/93	Japan			Abstract	
	07249618 A	9/26/95	Japan			Abstract	
	08242006 A	9/17/96	Japan			Abstract	
	S60-43485	3/8/85	Japan (Patent Disclosure)			X	
	H 02-155225	6/14/90	Japan (Patent Disclosure)			X	
	H3-185817	8/13/91	Japan (Patent Disclosure)			X	
	H3-187215	8/15/91	Japan (Patent Disclosure)			X	
	H3-91239	4/16/91	Japan (Patent Disclosure)			X	
✓	H5-62911	3/12/93	Japan (Patent Disclosure)			X	

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050702

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